



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 20, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

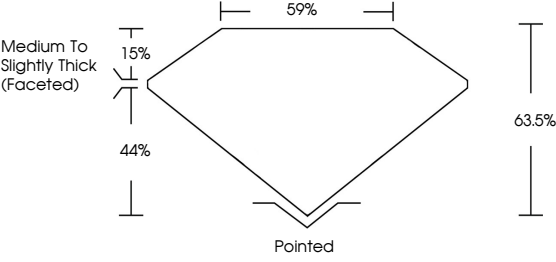
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG818693736

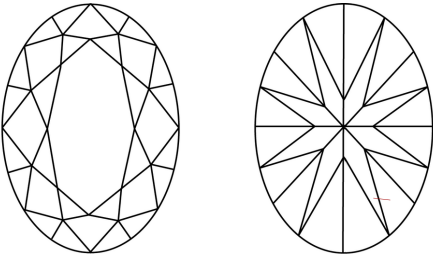
Report verification at igi.org

PROPORTIONS



Medium To Slightly Thick (Faceted)

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included



Sample Image Used



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LABORATORY GROWN DIAMOND

OVAL BRILLIANT

10.94 X 7.58 X 4.81 MM

2.54 CARATS

D

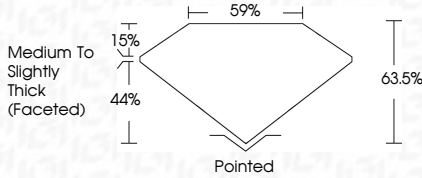
VS 1

EXCELLENT

EXCELLENT

NONE

IGI LG818693736



Medium To Slightly Thick (Faceted)



IGI

July 20, 2026

IGI Report No LG818693736

OVAL BRILLIANT

10.94 X 7.58 X 4.81 MM

2.54 CARATS

D

VS 1

63.5%

59%

Medium to Slightly Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG818693736

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



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